



# Contents of Volume 3

<i>Contents of volumes 1-4.</i>	v
<i>Foreword to volume 3.</i>	ix
<i>Contents of volume 3.</i>	xi
<i>Contributors to volume 3</i>	xiii
1. J. A. van Vechten <i>A simple man's view of the thermochemistry of semiconductors.</i>	1
2. P. J. Dean, A. G. Cullis and A. M. White <i>Characterization and properties of semiconductors.</i>	113
3. D. C. Miller and G. A. Rozgonyi <i>Defect characterization by etching, optical microscopy and X-ray topography.</i>	217
4. A. J. R. de Kock <i>Crystal growth of bulk crystals: purification, doping and defects.</i>	247
5. H. B. Pogue <i>Vapor phase epitaxy.</i>	335
6. J. J. Hsieh <i>Liquid-phase epitaxy.</i>	415
7. J. E. Greene <i>Crystal growth by sputtering.</i>	499
8. S. S. Lau, J. W. Mayer and W. Tseng <i>Solid phase epitaxial growth of Si and Ge.</i>	531
9. L. L. Chang <i>Molecular beam epitaxy.</i>	563
10. J. F. Gibbons <i>Ion implantation.</i>	599
11. W. A. Pliskin and R. A. Gdula <i>Passivation and insulation.</i>	641
12. G. A. N. Connell and R. A. Street <i>Amorphous semiconductors.</i>	689
13. F. Holtzberg, S. von Molnar and J. M. D. Coey <i>Rare earth magnetic semiconductors.</i>	803
14. C. L. Braun <i>Organic semiconductors.</i>	857
<i>Author index.</i>	875
<i>Subject index.</i>	917